IN THE UNITED STATES PATENT AND TRADEMARK OFFICE it Application of **NON-FEE AMENDMENT** KAMIYAMA et al. Group Art Unit: 1102 APPLICATION No.: 08/174,957 Filed: December 28, 1993 Examiner: W. Leader For: METHOD FOR SURFACE TREATMENT OF ALUMIN WAY ALLOY HIGH-TEMPERATURE PROCESSED ARTICLES GROUP 1100 RESPONSE TRANSMITTAL LETTER

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Enclosed is an amendment and response for the above-identified patent application.

- A Petition for Extension of Time is also enclosed. []
- Also enclosed is Reply to Examiner's Answer. [X]
- A Request for Entry and Consideration of Submission under 37 C.F.R. § 1.129(a) is also enclosed.
- [X] No additional claim fee is required.
- [] Charge \$\_\_\_\_\_ to Deposit Account No. 02-4800.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in triplicate.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

Charles H. Jew

Registration No. 34,192

P.O. Box 1404 Alexandria, Virginia 22313-1404 (415) 854-7400

Date: November 6, 1996



18/D Annie 11-13/1

Patent Attorney's Docket No. <u>024703-006</u>

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of	)	)	
S. Kamiyama, et al.	RECEIVED NOV 1 2 19	Group Art	Unit: 1102
Application No.: 08/174,957	)	Examiner:	W. Leader
Filed: December 28, 1993	GROUP 1)	100	
For: METHOD FOR SURFACE TREATMENT OF ALUMI	•	)	,
ALLOY HIGH-TEMPERA' PROCESSED ARTICLES	TURE )	) )	-

## AMENDMENT AND RESPONSE TO EXAMINER'S ANSWER

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Applicants submit the following Amendment in response to the Examiner's Answer to Appellants' Brief. Please amend Claims 1 and 17 as follows.

1. (Twice Amended) A method for treating the surface of an aluminum alloy high-temperature processed article, comprising heating an aluminum alloy containing Mg at a high temperature of 200° of above, etching the surface by a single step process of exposing the surface to [with] an aqueous solution containing a chelating agent wherein the aqueous solution consists of a solution having a pH of 7 or higher, and then carrying out hydration oxidation treatment.

